

**A METHOD OF FORMING A DEEP-FEATURED  
TEMPLATE EMPLOYED IN IMPRINT LITHOGRAPHY**

ABSTRACT OF THE DISCLOSURE

[0036] The present invention is directed to a method of forming a pattern on a plate employing a mold. The method includes placing the plate in superimposition with said mold. Formable material is positioned between that plate and the mold. A pattern is formed in the formable material having a shape complementary to the shape of the mold, defining patterned material. The patterned material is then adhered to the plate.